NAAI APPLICATION FORM

I.Basic Information

1.1 Basic Information (Mandatory)							
Name	Gender						
Date of Birth	Nationality					Passport Photo (Color, 2- inch)	
ID Type		ID No.					
Professional			Field of				
Title			Expertise				
Highest Edu.	Highest Degree						
Current			Position				
Employer			Position				
Work							
Address			ı	Г			
Mobile			Office Phone				
(Req'd)							
Home			Email (Req'd)				
Address							
Preferred Address	☐Home Address ☐Workplace Address						
Address							
		1.2 Ed	ucation Backgrou	ınd			
Period		ot.	Major		Degree		
1.3 Work Experience							
Start/End Date	Employer & Ti	Title	Address	Managed Staff		Responsibilities (R&D, Tech	
		THE		Direct	Indirect	Work)	

II. Principal Achievements of the Applicant

			2.1 Honors ar	nd Awards		
Award Date	Title of Honor	Awarding Org.			Level	
	1	I	2.2 Research	n Awards		
Award Date	Achievement Name	Awar	d Name	Rank	Awarding Org.	Remarks
	1	2.3 P	roject and Top	ı Dic Undertakir	ng	
Serial No.	Project/Topic Name	Category	Sponsoring Entity	Project Funding	Position	Remarks

Please list th	ne names of papers/publications, publication/publication is in the "Basic Information" column in order.	years, authors, ranking, and main			
Serial No.	Basic Info				
needed. Ple	eed Patents, Software Copyrights, etc. (Provide up to 30+, ase fill in the "Basic Information" column in order with the tent, approval year, patent number, inventor (designer),	e name of the implemented			
Serial No.	Basic Info				
2.6 Academic & Social Positions					
Start/End Date	Organization Name	Part-time Position			

III. Publ	cations Lis						
Serial No.	Serial No. Basic Information (Provide up to 30+, additional rows can be added)						
IV. Perso	nal Resume(Chinese, 2500-3000 words)						
	comprehensive, accurate, highlighting professional exp	pertise and contributions, etc. No					
fixed format, 2500-3000 words, Word document. First, outline personal educational experience, work							
experience, various part-time positions, important awards, honors, published papers, works, patents, etc.; second, focus on the main scientific and technological achievements and contributions.)							